



PHE102 Variable Angle Spectroscopic Ellipsometer Angstrom Advanced

Instruments for Thin Film and Semiconductor Applications

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VARIABLE ANGLE SPECTROSCOPIC ELLIPSOMETERS

PhE102-VASE is the most powerful and versatile ellipsometer for research on a wide range of materials: dielectrics, polymers, semiconductors, metals, multilayers, etc. It covers the widest spectral range with the highest spectral resolution. This system is controlled by a remote computer located in the system control module. This instrument is affordable, high quality, and used widely in both academia and industry.



Nondestructive Characterize of Thin Films and Bulk Materials

- Film Thickness and Optical Constants
- Broad Range of Film Thickness (sub-nm to 30 μm)
- A Variety of Substrates: Metals, Semiconductors, Glass, etc.
- Multilayer Structures
- Surface and Interfacial Roughness
- Bandgap and Electronic Transitions
- Composition
- Crystallinity

Accessorial Options

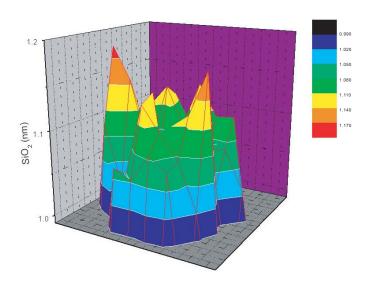
- Micro Spot Focus Optics
- Automated Sample Translation
- Hardware and software for In-situ mounting
- Sample Heater
- Liquid/Electrochemical Cells
- Mapping

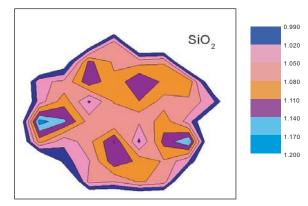
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3D Mapping and Contour





phE-102 Horizontal VASE



PhE-102 is the most versatile and powerful Spectroscopic Ellipsometer. It features a horizontal mounting stage to handle large sample sizes and can incorporate sample mapping.

Rotating polarizer for any polarization state (ψ :0° to 90°,

 Δ : 0° to 360°), the highest accuracy for any sample;

Large angle of incidence range from 20° to 90°,

Easy sample alignment with vertical laser technology;

Accurate wavelength selection and wide spectral range (up 2500 wavelengths);

Fast operation for multi-angle measurements;

Versatile Integration for in-site, fixed angle, multi-angle or automated angle.

Available Sub-Models

S: 350 nm to 850 nm (1000 wavelengths)

U: 250 nm to 1100 nm (1500 wavelengths)

E: 250 nm to 2300 nm (2300 wavelengths)

G: 193 nm to 1700 nm (2000 wavelengths)

N: 350 nm to 1700 nm (1800 wavelengths)

V: 250 nm to 1700 nm (1900 wavelengths)

D: 193 nm to 1100 nm (1600 wavelengths)

F; 193 nm to 2300 nm (2500 wavelengths)

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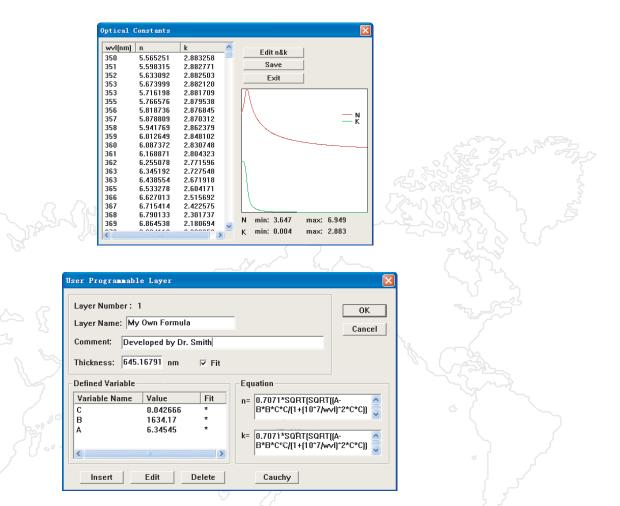
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PhE Acquisition and Analysis Software

PhE is a very comprehensive program for data acquisition and analysis. It utilizes sophisticated mathematical fitting algorithms for accurate and fast data analysis of both simple and complex structures.

- Own large tabulated optical constant database (materials library);
- Push-button procedure for measurement of routine samples;
- Versatile recipes for data acquisition, data analysis and mapping;
- Integrate normal dispersion models to describe material optical constants;
- Automatic backside correction/correlated layers;
- Include surface and interfacial roughness analysis
- Build user-defined models and database
- Generate Psi and Delta with any sample structures
- Give reliability analysis of the fitting parameters



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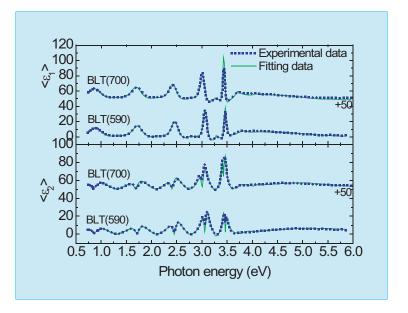
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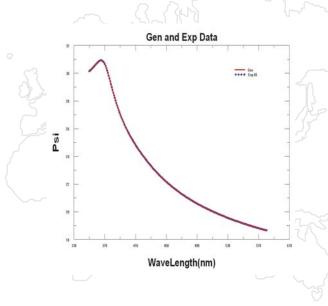
Example: Multilayer Structure

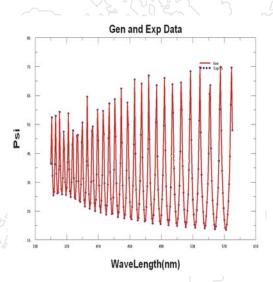
3 Surface Rough Layer	11.6 nm
2 BLT Films	321.4 nm
1 SiO2	21.5 nm
0 Si	1 mm





Example: Thick Film Structure Example: Thin Film Str		in Film Structure	
1 SiO2	10.0 mm	1 Au	1.0 nm
0 Si	1 mm	0 Si	1 mm





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